

Microcontact spectroscopy of the CeCu_2Si_2 Kondo lattice

Yu. G. Neĭdyuk, N. N. Grivbov, A. A. Lysykh, I. K. Yanson, N. B. Brandt,¹⁾ and V. V. Moshchalkov¹⁾

Physicotechnical Institute of Low Temperatures, Academy of Sciences of the Ukrainian SSR

(Submitted 22 February 1985)

Pis'ma Zh. Eksp. Teor. Fiz. **41**, No. 8, 325–328 (15 April 1985)

The strong electron-electron interaction causes current flow in a thermal regime in CeCu_2Si_2 microcontacts. The conductivity of CeCu_2Si_2 -Cu heterocontacts is found to be asymmetric with respect to the current direction. This asymmetry is attributed to a resonance in the CeCu_2Si_2 state density near the Fermi level.

1. Considerable interest has recently been attracted to the kinetic phenomena in the compound CeCu_2Si_2 , which exhibits several unusual properties at low temperatures.^{1–4} This material falls in the category of so-called Kondo lattices, which constitute a new class of solids, according to Ref. 4. At temperatures $T_K \sim 10$ K (T_K is the Kondo temperature), there is a maximum in the electron energy spectrum near the Fermi level in CeCu_2Si_2 . This maximum, known as the Abrikosov-Suhl resonance, is responsible for the anomalous properties of CeCu_2Si_2 . The presence of a narrow resonance gives rise to quasiparticles with a large effective mass ($m^* \approx 200m_0$)—"heavy fermions"—and to a low degeneracy temperature, $T_F^* \sim 10$ K. At $T < T_K$, the magnetic moments of cerium are screened by conduction electrons, and the CeCu_2Si_2 goes into a nonmagnetic state. There is accordingly interest in studying the properties of CeCu_2Si_2 by the method of microcontact spectroscopy, which has been widely used to study various mechanisms for the energy relaxation of electrons in conductors.⁵

2. Figure 1a shows the differential resistance $R_D(V) = dV/dI(V)$ of a CeCu_2Si_2 microcontact; there are two maxima, at 5 and 67 mV. As $V \rightarrow 0$, the function $R_D(V)$ is

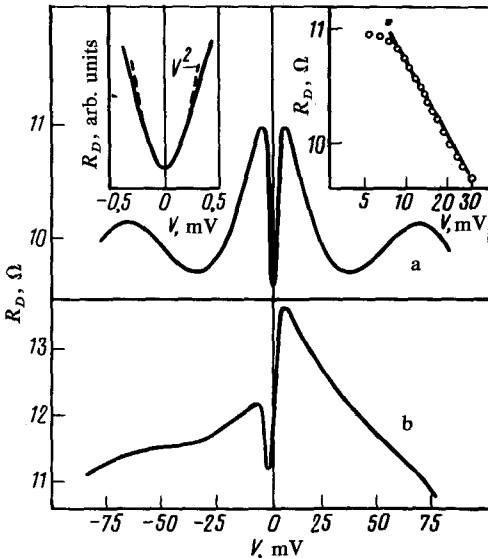


FIG. 1. The differential resistance $R_D(V)$ of a CeCu_2Si_2 microcontact at $T_0 = 2.4$ K (a) and of a CeCu_2Si_2 -Cu heterocontact at $T_0 = 4.2$ K (b) (at $V > 0$, the current flows from Cu to CeCu_2Si_2).

quadratic, $R_D(V) = R(0) + aV^2$, while between 7 and 30 mV it falls off logarithmically (see the inset in Fig. 1a). The function $R_D(V)$ is thus qualitatively similar to $\rho(T)$ of a bulk sample.⁴ The correlation between $R_D(V)$ and $\rho(T)$ is evidence of a thermal regime for the current flow in CeCu_2Si_2 contacts, in which the temperature T in the contact is related to the voltage across it by⁶

$$T^2 = T_0^2 + V^2/4L, \quad (1)$$

where T_0 is the temperature of the bath, and L is the Lorentz number.

According to the theory for the thermal regime,⁶ we can use the measured curves of $R_D(V)$ to calculate the temperature dependence of the resistance of the microcontact, $R_{\text{mc}}^{\text{theo}}(T)$, using the linear relation (1) between T and V ($V = \alpha T$) at $T^2 \gg T_0^2$:

$$R_{\text{mc}}^{\text{theo}}(T) = R_{\text{mc}}^{\text{theo}}(V/\alpha) = \pi/2 \left[\int_0^V R_D^{-1}(v) (V^2 - v^2)^{-1/2} dv \right]^{-1}.$$

Figure 2 shows experimental results on the microcontact resistance versus the temperature,²⁾ $R_{\text{mc}}(T)$, in comparison with $R_{\text{mc}}^{\text{theo}}(T)$. In order to bring the extrema of the $R_{\text{mc}}^{\text{theo}}(T)$ curve into coincidence with those of the $R_{\text{mc}}(T)$ curve, we need to assign L in (1) the value $1.25 \times 10^{-7} \text{ V}^2/\text{K}^2$; i.e., we need $L/L_0 \approx 5$, where L_0 is the standard value for the Lorentz number. We see that there is a good correlation between the calculated and experimental curves in both shape and absolute values; the significant discrepancy at $T < 6 \text{ K}$ is due to a violation of the inequality $T^2 \gg T_0^2$. The value $L/L_0 \approx 5$ which we find in the interval 10–100 K agrees satisfactorily with the data of Ref. 3 in view of the strong dependence of the properties of CeCu_2Si_2 on the direction in the single crystal, on the structural quality, and on the stoichiometry. For a more precise comparison with experiment, we would need to correct the theory of the thermal regime for the temperature dependence $L(T)$, and we would also need to take into account the circumstance that the strong electron-electron interaction in CeCu_2Si_2 may make the effective temperature of the electron subsystem different from the lattice temperature.

3. The main distinguishing feature of the $R_D(V)$ curves for CeCu_2Si_2 -Cu heterocontacts is their asymmetry with respect to the $V = 0$ axis (Fig. 1b). An asymmetry of

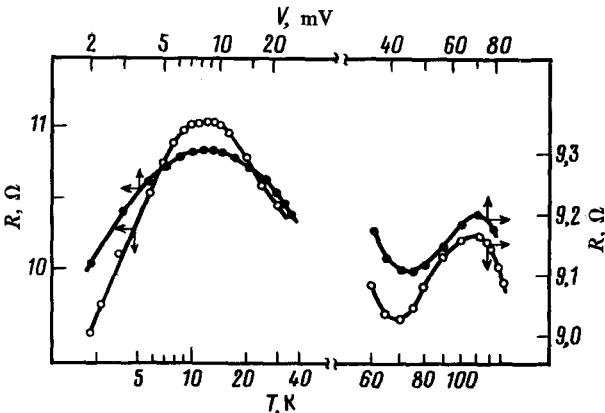


FIG. 2. Comparison of the experimental (O) temperature dependence of the resistance of a CeCu_2Si_2 microcontact with the theoretical (●) behavior. The V scale is drawn in accordance with Eq. (1), where $L = 1.25 \times 10^{-7} \text{ V}^2/\text{K}^2$ and $T_0 = 0$.

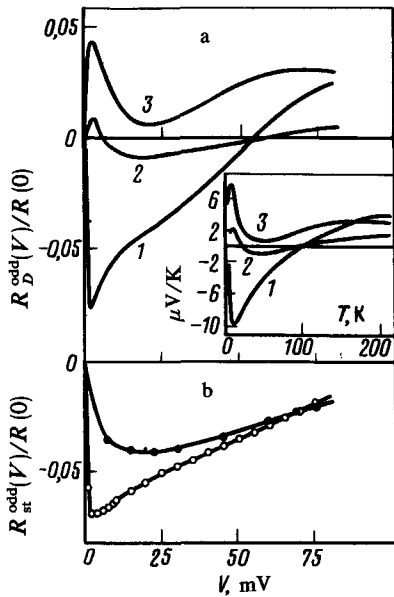


FIG. 3. a—Experimental results on $R_D^{\text{odd}}(V)$ for heterocontacts between Cu and (1) CeCu_2Si_2 , (2) $\text{Ce}_{0.7}\text{La}_{0.3}\text{Cu}_2\text{Si}_2$, and (3) $\text{Ce}_{0.3}\text{La}_{0.7}\text{Cu}_2\text{Si}_2$. The inset shows $S(T)$ for these compounds⁴; b—comparison of the theoretical dependence $R_{\text{st}}^{\text{odd}}(V)/R(0)$, calculated from (2), for a CeCu_2Si_2 -Cu heterocontact (●) with experimental data (○).

$R_D(V)$ curves has been observed previously for heterocontacts of Mo or Pt with a valence fluctuation compound^{8,9} and, by O. I. Shklyarevskii, A. G. M. Jansen,³ I. K. Janson, and the first two of the present authors for heterocontacts of a normal metal with a ferromagnetic metal and with dilute magnetic alloys, Cu-Fe and Cu-Mn (the results are to be published). It has been suggested in these studies that the observed asymmetry may be due to a manifestation of the Seebeck and/or Peltier effect in the thermal regime. That these effects do influence the asymmetry of $R_D(V)$ is shown clearly by the correlation between the odd part of the differential resistance, $R_D^{\text{odd}}(V) = \frac{1}{2}[R_D^+(V) - R_D^-(V)]$, of heterocontacts of copper with CeCu_2Si_2 and of two of its alloys, and the absolute thermal emf of these substances (see Fig. 3 and the inset). This correlation has been mentioned⁹ for other compounds.

Analyzing these effects, we find that we would have

$$R_{\text{st}}^{\text{odd}}(V)/R(0) \approx \int_{T_0}^T [S_1(T) - S_2(T)] dT/V \quad (2)$$

in the case of the Seebeck effect or

$$R_{\text{st}}^{\text{odd}}(V) \approx \partial R_{\text{st}} / \partial T [S_1(T) - S_2(T)] T^2/V \quad (3)$$

in the case of Peltier effect, where $R_{\text{st}}^{\text{odd}} = (1/2)(R_{\text{st}}^+ - R_{\text{st}}^-)$, R_{st}^+ and R_{st}^- are the static resistances of the microcontact for the two polarities [$R_{\text{st}} = V/I(V) = V/\int_0^V R_D^-(v) dv$], and S_1 , and S_2 are the thermal emf's of the materials in the contact.

Figure 3b shows the resistance $R_{\text{st}}^{\text{odd}}$ calculated from (2), in comparison with experimental results. In these calculations we used data from Ref. 1 on $S(T)$, and we

assumed a linear relation between V and T , $V = (0.7 \text{ mV/K})T$, in accordance with the conclusions of the preceding section. We see that the experimental and theoretical results agree well at $V \gtrsim 50 \text{ mV}$, but at energies $eV \sim 10 \text{ meV}$ or at temperatures $T \sim 10 \text{ K}$ there is a substantial discrepancy between the curves. The Peltier effect does not improve the agreement, since its contribution is several times smaller than that of the Seebeck effect according to (3) with $V \approx 5 \text{ mV}$ ($\partial R_{\text{st}}/\partial T$ reaches a maximum value $\sim 0.1 \Omega/\text{K}$ at $R_{\text{st}} \approx 10 \Omega$).

In summary, the asymmetry of $R_D(V)$ of heterocontacts cannot be explained entirely by thermoelectric effects, especially at $T \sim 10 \text{ K}$, where there is a sharp maximum in the density of electronic states of CeCu_2Si_2 . As the temperature is raised, this maximum on the curve of $g(\epsilon)$ at $\epsilon = \epsilon_F$ becomes rounded, and (Fig. 3b) the difference between the theoretical and experimental values of $R_{\text{st}}^{\text{odd}}$ decreases. These circumstances indicate that the asymmetric feature on $g(\epsilon)$ in CeCu_2Si_2 is apparently responsible for the asymmetry of $R_D(V)$ at low energies.

¹M. V. Lomonosov State University, Moscow.

²Knowing the functional dependence $R_{\text{mc}}(T)$, we can estimate the size (d) of the contact and the elastic electron mean free path l_i , in accordance with Ref. 7. We find $d \sim 2000 \text{ \AA}$ and $l_i \sim 5 \text{ \AA}$ for the contact in Fig. 1a. Consequently, the condition $d \gg l_i$, one of the necessary conditions for the thermal regime, is satisfied.⁶

³University of Nijmegen, The Netherlands.

¹W. Franz *et al.*, Z. Phys. **B31**, 7 (1978).

²F. Steglich *et al.*, Phys. Rev. Lett. **43**, 1892 (1979).

³H. Schneider *et al.*, Solid State Commun. **48**, 1093 (1983).

⁴F. G. Aliev *et al.*, J. Low Temp. Phys. **57**, 61 (1984).

⁵A. G. M. Jansen, A. P. van Gelder, and P. Wyder, J. Phys. C **13**, 6073 (1980).

⁶B. I. Verkin *et al.*, Izv. Akad. Nauk SSSR, Ser. Fiz. **44**, 1330 (1980).

⁷A. I. Akimenko *et al.*, Fiz Nizk. Temp. **8**, 260 (1982) [Sov. J. Low Temp. Phys. **8**, 130 (1982)].

⁸B. Bussian, F. Frankowski, and D. Wohlleben, Phys. Rev. Lett. **49**, 1026 (1982).

⁹E. Paulus and G. Voss, in: Proceedings of the Fourth International Conference on Valence Fluctuations, Cologne, FRG, 1984.